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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/709,752	05/26/2004	Kohichi Ohsumi	JP920030018US1	3751
32074 7590 10/05/2007 INTERNATIONAL BUSINESS MACHINES CORPORATION			EXAMINER	
DEPT. 18G BLDG. 300-482	CHANG, RICK KILTAE			
2070 ROUTE 5		•	ART UNIT	PAPER NUMBER
HOPEWELL JUNCTION, NY 12533			3726	
			MAIL DATE	DELIVERY MODE
			10/05/2007	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

•	Application No.	Applicant(s)
	10/709,752	OHSUMI ET AL.
Office Action Summary	Examiner	Art Unit
	Rick K./ /Chang	3726
The MAILING DATE of this communication	appears on the cover sheet w	ith the correspondence address
Period for Reply		
A SHORTENED STATUTORY PERIOD FOR RE WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFF after SIX (6) MONTHS from the mailing date of this communication If NO period for reply is specified above, the maximum statutory per - Failure to reply within the set or extended period for reply will, by sta Any reply received by the Office later than three months after the may earned patent term adjustment. See 37 CFR 1.704(b).	B DATE OF THIS COMMUNI R 1.136(a). In no event, however, may a riod will apply and will expire SIX (6) MON atute, cause the application to become Al	CATION. reply be timely filed  NTHS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).
Status		
1) Responsive to communication(s) filed on 24	4 September 2007.	_
	his action is non-final.	
3)☐ Since this application is in condition for allo	wance except for formal mat	ters, prosecution as to the merits is
closed in accordance with the practice unde	er <i>Ex parte Quayle</i> , 1935 C.E	D. 11, 453 O.G. 213.
Disposition of Claims		
4)⊠ Claim(s) <u>1-13</u> is/are pending in the application	ion.	
4a) Of the above claim(s) is/are without		
5)⊠ Claim(s) <u>5-13</u> is/are allowed.		
6)⊠ Claim(s) <u>1-4</u> is/are rejected.		
7) Claim(s) is/are objected to.		
8) Claim(s) are subject to restriction an	d/or election requirement.	
Application Papers		
9) The specification is objected to by the Exam	niner	
10) ☐ The drawing(s) filed on is/are: a) ☐ a		by the Examiner.
Applicant may not request that any objection to t		
Replacement drawing sheet(s) including the corr		• •
11) The oath or declaration is objected to by the		
Priority under 35 U.S.C. § 119		
12) Acknowledgment is made of a claim for fore	ian priority under 35 U.S.C. 8	S 119(a)-(d) or (f)
a) ☐ All b) ☐ Some * c) ☐ None of:	ight priority under do dio.o. 3	3
1. Certified copies of the priority docume	ents have been received.	
2. Certified copies of the priority docume	•	Application No
3. Copies of the certified copies of the p		
application from the International Bur		
* See the attached detailed Office action for a	list of the certified copies not	received.
Attachment(s)	<b>-</b>	<b>1</b>
<ul> <li>Notice of References Cited (PTO-892)</li> <li>Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> </ul>		Summary (PTO-413) s)/Mail Date
) Information Disclosure Statement(s) (PTO/SB/08)	·	nformal Patent Application

## **DETAILED ACTION**

## Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 9/24/07 has been entered.

## Claim Rejections - 35 USC § 112

- 2. Claims 1-4 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention. The disclosure, as originally filed, failed to provide support for forming a land (claim 1, line 6) before adjusting a thickness of the plating layer and forming areas of the metal foils not cover covered by the plating layer into lines steps. The forming the land step occurs after adjusting a thickness of the plating layer and forming areas of the metal foils steps as shown in Fig. 10. The disclosure, as originally filed, failed to provide support for performing claims 3-4 after forming areas of the metal foils not cover covered by the plating layer into lines steps.
- 3. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

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Claims 1-13 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for 4. failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claims 1-4 are rejected under 35 U.S.C. 112, second paragraph, as being incomplete for omitting essential steps, such omission amounting to a gap between the steps. See MPEP § 2172.01. The omitted steps are: forming an opening in the metal foils and the insulating substrate, forming a first resist pattern on the metal foils, removing the first resist pattern, forming a second resist pattern, etc.

Claim 5, line 6: "said metal foil" lacks positive antecedent bais.

Claim 5, lines 7-8: "the exposed metal foil" lacks positive antecedent basis.

Claims 1-4 are rejected under 35 U.S.C. 112, second paragraph, as being incomplete for omitting essential steps, such omission amounting to a gap between the steps. See MPEP § 2172.01. The omitted steps are: removing the first resist pattern; forming a second resist patter on the areas of the metal foil; selectively forming an exposed portion of the areas of the metal foil using the second resist pattern; etching the metal foil at the exposed protion; removing the second resist pattern; forming a dielectric layer on the insulating substrate and on the plating layer and the lines on the metal foil; forming an opening in the plating layer; and performing plating on the opening.

Claims 1-13 are ambiguous as being incomplete for omitting essential steps and competitors would be unable to discern the bounds of the invention.

## **Conclusion**

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- 5. Please provide reference numerals (either in parentheses next to the claimed limitation or in a table format with one column listing the claimed limitation and another column listing corresponding reference numerals in the remark section of the response to the Office Action) to all the claimed limitations as well as support in the disclosure for better clarity (optional). Applicants are duly reminded that a full and proper response to this Office Action that includes any amendment to the claims and specification of the application as originally filed requires that the applicant point out the support for any amendment made to the disclosure, including the claims. See 37 CFR 1.111 and MPEP 2163.06.
- 6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Rick K. Chang whose telephone number is (571) 272-4564. The examiner can normally be reached on 5:30 AM to 1:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David P. Bryant can be reached on (571) 272-4526. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

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/Rick K. Chang/ Primary Examiner, A.U. 3726

RC September 29, 2007